

650V Cascode GaN FET in TO-247 (source tab)

Description

The TP65H050WS 650V, $50m\Omega$ Gallium Nitride (GaN) FET is a normally-off device. It combines state-of-the-art high voltage GaN HEMT and low voltage silicon MOSFET technologies—offering superior reliability and performance.

Transphorm GaN offers improved efficiency over silicon, through lower gate charge, lower crossover loss, and smaller reverse recovery charge.

Related Literature

- ANOOOO: Recommended External Circuitry for GaN FETs
- ANOOO3: Printed Circuit Board Layout and Probing
- ANOO10: Paralleling GaN FETs

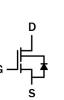
Ordering Information

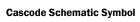
| Part Number | Package | Package Configuration |
|-------------|---------------|--------------------------|
| TP65H050WS | 3 Lead T0-247 | Source |

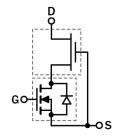
TP65H050WS TO-247 (top view)











Cascode Device Structure

Features

- JEDEC qualified GaN technology
- Dynamic R_{DS(on)eff} production tested
- · Robust design, defined by
 - Intrinsic lifetime tests
 - Wide gate safety margin
 - Transient over-voltage capability
- Very low Q_{RR}
- Reduced crossover loss
- · RoHS compliant and Halogen-free packaging

Benefits

- Improves efficiency/operation frequencies over Si
- Enables AC-DC bridgeless totem-pole PFC designs
 - Increased power density
 - Reduced system size and weight
 - Overall lower system cost
- Easy to drive with commonly-used gate drivers
- · GSD pin layout improves high speed design

Applications

- Datacom
- Broad industrial
- PV inverter
- · Servo motor

| Key Specifications | | | |
|---------------------------------|-----|--|--|
| V _{DSS} (V) | 650 | | |
| V _{(TR)DSS} (V) | 800 | | |
| $R_{DS(on)eff}(m\Omega)\;max^*$ | 60 | | |
| Q _{RR} (nC) typ | 125 | | |
| Q _G (nC) typ | 16 | | |

^{*} Dynamic on-resistance; see Figures 17 and 18

| Common Topology Power Recommendations | | | | |
|---------------------------------------|-----------|--|--|--|
| CCM bridgeless totem-pole* | 3080W max | | | |
| Hard-switched inverter** | 3670W max | | | |

Conditions: F_{SW}=45kHz; T_J=115°C; T_{HEATSINK}=90°C; insulator between device and heatsink (6 mil Sil-Pad® K-10); power de-rates at lower voltages with constant current

- VIN=230VAC; VOUT=390VDC
- V_{IN} =380 V_{DC} ; V_{OUT} =240 V_{AC}

Absolute Maximum Ratings (T_c=25 °C unless otherwise stated.)

| Symbol | Parameter | | Limit Value | Unit |
|-------------------------|--|----------------------------------|-------------|------|
| V_{DSS} | Drain to source voltage (T _J = -5 | 5°C to 150°C) | 650 | |
| $V_{(TR)DSS}$ | Transient drain to source volta | ge ^a | 800 | V |
| V _{GSS} | Gate to source voltage | | ±20 | |
| P _D | Maximum power dissipation @ | T _C =25°C | 119 | W |
| | Continuous drain current @T _C =25°C b | | 36 | А |
| l _D | Continuous drain current @T _C = | nuous drain current @Tc=100°C b | | А |
| I _{DM} | Pulsed drain current (pulse width: 10µs) | | 150 | А |
| (di/dt) _{RDMC} | Reverse diode di/dt, repetitive ° | | 1600 | A/µs |
| (di/dt) _{RDMT} | Reverse diode di/dt, transient | Reverse diode di/dt, transient d | | A/µs |
| Tc | | | -55 to +150 | °C |
| ΤJ | Operating temperature | Junction | -55 to +150 | °C |
| Ts | Storage temperature Soldering peak temperature e Mounting Torque | | -55 to +150 | °C |
| T _{SOLD} | | | 260 | °C |
| - | | | 80 | N cm |

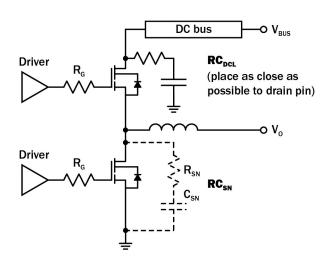
Notes:

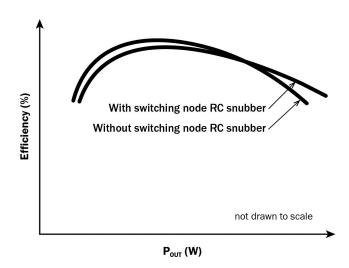
- In off-state, spike duty cycle D<0.01, spike duration <1µs
- For increased stability at high current operation, see Circuit Implementation on page 3 Continuous switching operation b.
- ≤300 pulses per second for a total duration ≤20 minutes
- For 10 sec., 1.6mm from the case

Thermal Resistance

| Symbol | Parameter | Maximum | Unit |
|------------------|---------------------|---------|------|
| R _{OJC} | Junction-to-case | 1.05 | °C/W |
| R _{OJA} | Junction-to-ambient | 40 | °C/W |

Circuit Implementation





Simplified Half-bridge Schematic

Efficiency vs Output Power

Recommended gate drive: (0V, 12V) with R_G = 30-45 Ω

| Required DC Link RC Snubber (RC _{DCL}) ^a | Recommended Switching Node RC Snubber (RC _{SN}) b, c | | | |
|---|--|--|--|--|
| [10nF + 8Ω] x 2 | 100pF + 10Ω | | | |

Notes:

- a. RC_{DCL} should be placed as close as possible to the drain pin
- b. A switching node RC snubber (C, R) is recommended for high switching currents (>70% of IRDMC1 or IRDMC2; see page 5 for IRDMC1 and IRDMC2)
- c. I_{RDM} values can be increased by increasing R_G and C_{SN}

Electrical Parameters (T_J=25 °C unless otherwise stated)

| Symbol | Parameter | Min | Тур | Max | Unit | Test Conditions |
|---|--|-----|------|------|-------|--|
| Forward Device Characteristics | | | | | | |
| $V_{(BL)DSS}$ | Drain-source voltage | 650 | _ | _ | V | V _{GS} =0V |
| $V_{\text{GS(th)}}$ | Gate threshold voltage | 3.3 | 4 | 4.8 | V | V _{DS} =V _{GS} , I _D =0.7mA |
| $\Delta V_{\text{GS(th)}}\!/T_{\text{J}}$ | Gate threshold voltage temperature coefficient | _ | -6.2 | _ | mV/°C | |
| R _{DS(on)eff} | Drain cource on recistance a | _ | 50 | 60 | mΩ | V _{GS} =10V, I _D =22A |
| NDS(on)eff | Drain-source on-resistance ^a | _ | 103 | _ | 11122 | V _{GS} =10V, I _D =22A, T _J =150°C |
| | Dunin to account lands account | _ | 2.5 | 25 | | V _{DS} =650V, V _{GS} =0V |
| I _{DSS} | Drain-to-source leakage current | _ | 10 | _ | μA | V _{DS} =650V, V _{GS} =0V, T _J =150°C |
| | | _ | _ | 100 | | V _{GS} =20V |
| I _{GSS} | Gate-to-source forward leakage current | _ | _ | -100 | nA | V _{GS} =-20V |
| C _{ISS} | Input capacitance | _ | 1000 | _ | | V _{GS} =0V, V _{DS} =400V, <i>f</i> =1MHz |
| Coss | Output capacitance | _ | 130 | _ | рF | |
| C _{RSS} | Reverse transfer capacitance | _ | 8 | _ | | |
| C _{O(er)} | Output capacitance, energy related b | _ | 190 | _ | _ | V _{GS} =0V, V _{DS} =0V to 400V |
| C _{O(tr)} | Output capacitance, time related ° | _ | 310 | _ | pF | |
| Q _G | Total gate charge | _ | 16 | 24 | | V_{DS} =400V, V_{GS} =0V to 10V, I_{D} =22A |
| Q _{GS} | Gate-source charge | _ | 6 | _ | nC | |
| Q _{GD} | Gate-drain charge | _ | 5 | _ | | |
| Qoss | Output charge | _ | 124 | _ | nC | V _{GS} =0V, V _{DS} =0V to 400V |
| t _{D(on)} | Turn-on delay | _ | 51 | _ | | |
| t _R | Rise time | _ | 11 | _ | | V_{DS} =400V, V_{GS} =0V to 12V, I_{D} =22A, R_{G} = 40 Ω |
| $t_{\text{D(off)}}$ | Turn-off delay | _ | 86 | _ | ns | |
| t _F | Fall time | _ | 11 | _ | | |

Notes:

a. Dynamic on-resistance; see Figures 17 and 18 for test circuit and conditions

b. Equivalent capacitance to give same stored energy as V_{DS} rises from 0V to 400V

c. Equivalent capacitance to give same charging time as V_{DS} rises from OV to 400V

Electrical Parameters (T_J=25 °C unless otherwise stated)

| Symbol | Symbol Parameter | | Тур | Max | Unit | Test Conditions |
|--|---|---|-----|------|------|--|
| Reverse Device Characteristics | | | | | | |
| I _S Reverse current | | _ | _ | 22 | А | V _{GS} =0V, T _C =100°C, ≤20% duty cycle |
| V_{SD} | Reverse voltage ^a | _ | 1.8 | 2.3 | V | V _{GS} =0V, I _S =22A |
| VSD | | _ | 1.3 | 1.7 | | V _{GS} =0V, I _S =11A |
| t _{RR} | Reverse recovery time | _ | 54 | _ | ns | I _S =22A, V _{DD} =400V, |
| Q_{RR} | Reverse recovery charge | _ | 125 | _ | nC | di/dt=1000A/µs |
| (di/dt) _{RDMC} | Reverse diode di/dt, repetitive b | _ | _ | 1600 | A/µs | |
| I _{RDMC1} | Reverse diode switching current, repetitive (dc) c, e | _ | _ | 24 | А | Circuit implementation and parameters on page 3 |
| I _{RDMC2} | Reverse diode switching current, repetitive (ac) c, e | _ | _ | 28 | А | Circuit implementation and parameters on page 3 |
| (di/dt) _{RDMT} | Reverse diode di/dt, transient d | _ | _ | 3000 | A/µs | |
| Reverse diode switching current, transient de ent de | | _ | _ | 36 | А | Circuit implementation and parameters on page 3 |

Notes:

- a. Includes dynamic $R_{DS(on)}$ effect
- b. Continuous switching operation
- c. Definitions: dc = dc-to-dc converter topologies; ac = inverter and PFC topologies, 50-60Hz line frequency
- d. ≤300 pulses per second for a total duration ≤20 minutes
- e. I_{RDM} values can be increased by increasing R_{G} and C_{SN} on page 3

Typical Characteristics (T_C=25 °C unless otherwise stated)

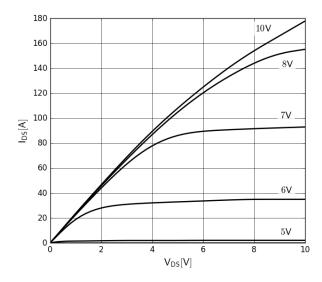


Figure 1. Typical Output Characteristics T_J=25 °C

Parameter: V_{GS}

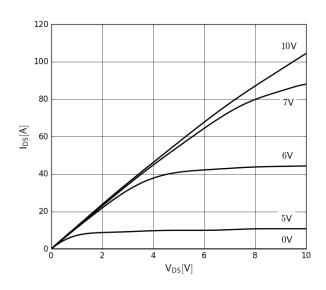


Figure 2. Typical Output Characteristics T_J=150 °C

Parameter: V_{GS}

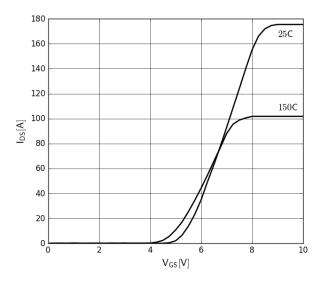


Figure 3. Typical Transfer Characteristics V_{DS} =10V, parameter: T_J

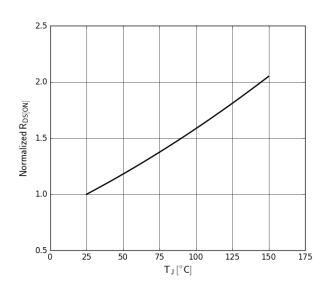


Figure 4. Normalized On-resistance $I_D=22A,\ V_{GS}=10V$

Typical Characteristics (T_C=25 °C unless otherwise stated)

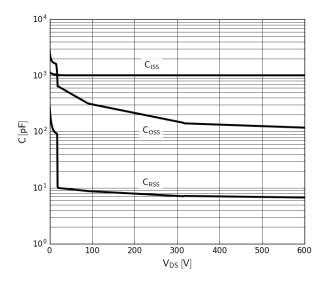


Figure 5. Typical Capacitance V_{GS} =0V, f=1MHz

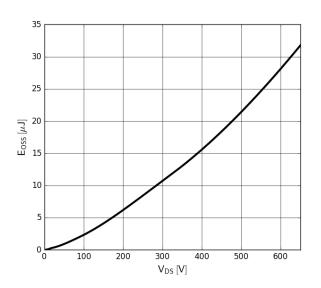


Figure 6. Typical Coss Stored Energy

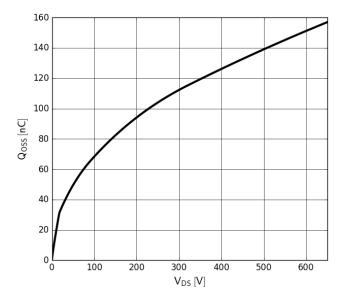


Figure 7. Typical Qoss

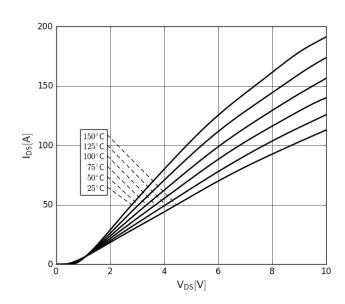


Figure 8. Forward Characteristics of Rev. Diode $I_S {=} f(V_{SD}), \ parameter {:} \ T_J$

Typical Characteristics (T_C=25 °C unless otherwise stated)

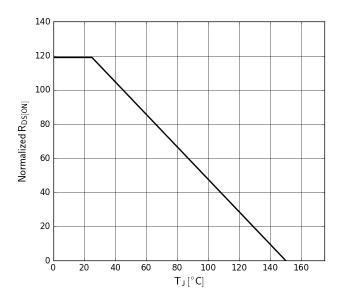


Figure 9. Power Dissipation

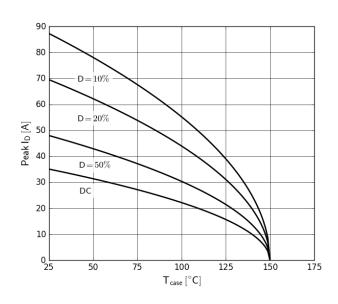


Figure 10. Current Derating Pulse width \leq 10µs, $V_{GS} \geq$ 10V

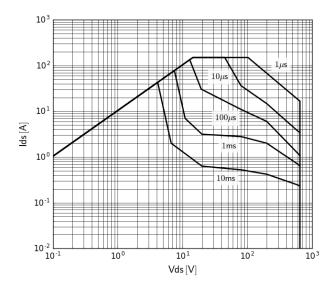


Figure 11. Safe Operating Area $T_C=25$ °C

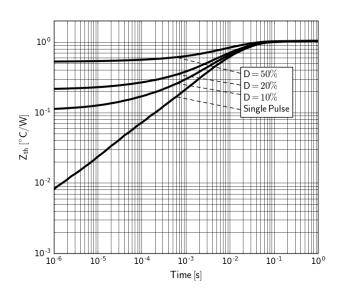


Figure 12. Transient Thermal Resistance

Test Circuits and Waveforms

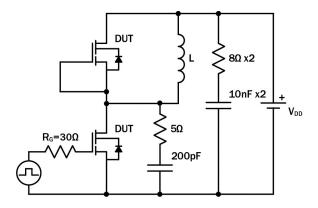


Figure 13. Switching Time Test Circuit (see circuit implementation on page 3 for methods to ensure clean switching)

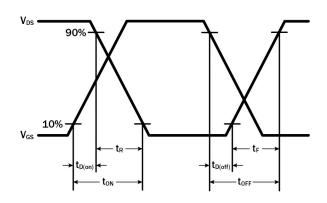


Figure 14. Switching Time Waveform

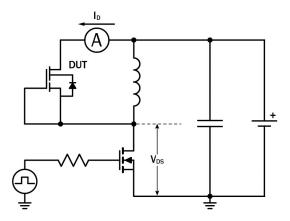


Figure 15. Diode Characteristics Test Circuit

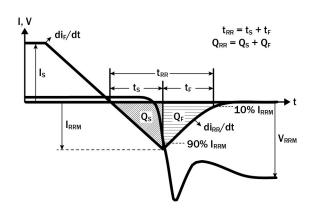


Figure 16. Diode Recovery Waveform

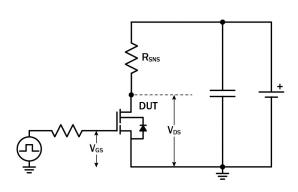


Figure 17. Dynamic R_{DS(on)eff} Test Circuit

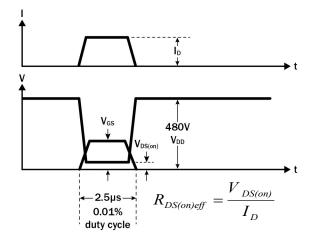


Figure 18. Dynamic R_{DS(on)eff} Waveform

Design Considerations

The fast switching of GaN devices reduces current-voltage crossover losses and enables high frequency operation while simultaneously achieving high efficiency. However, taking full advantage of the fast switching characteristics of GaN switches requires adherence to specific PCB layout guidelines and probing techniques.

Before evaluating Transphorm GaN devices, see application note <u>Printed Circuit Board Layout and Probing for GaN Power Switches</u>. The table below provides some practical rules that should be followed during the evaluation.

When Evaluating Transphorm GaN Devices:

| DO | DO NOT |
|---|--|
| Minimize circuit inductance by keeping traces short, both in the drive and power loop | Twist the pins of TO-220 or TO-247 to accommodate GDS board layout |
| Minimize lead length of TO-220 and TO-247 package when mounting to the PCB | Use long traces in drive circuit, long lead length of the devices |
| Use shortest sense loop for probing; attach the probe and its ground connection directly to the test points | Use differential mode probe or probe ground clip with long wire |
| See AN0003: Printed Circuit Board Layout and Probing | |

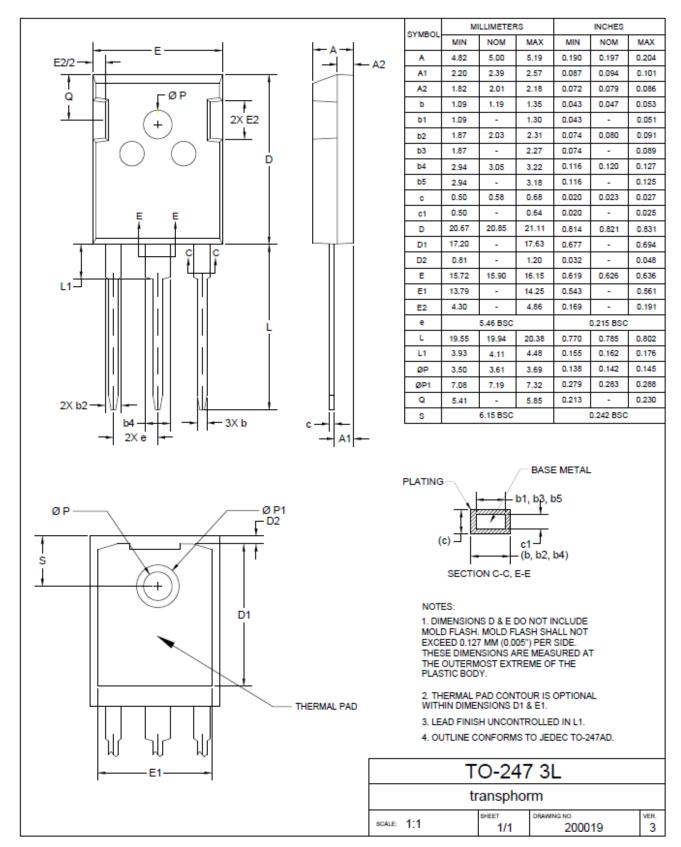
GaN Design Resources

The complete technical library of GaN design tools can be found at transphormusa.com/design:

- Evaluation kits
- Application notes
- · Design guides
- · Simulation models
- Technical papers and presentations

Mechanical

3 Lead TO-247 Package



Revision History

| Version | Date | Change(s) | |
|---------|------------|---|--|
| 0 | 12/6/2017 | nitial | |
| 1 | 6/13/2018 | Datasheet completed | |
| 2 | 12/21/2018 | Add max mounting torque Update maximum continuous current Update Qoss Switching with current test condition | |